L	Hits	Search Text	DB	Time stamp
Number				
1	8993	((Chemical adj mechanical adj polish\$3)	USPAT;	2002/02/08
		or CMP or planariz\$5) and (slurry or	US-PGPUB;	14:56
		composition)	EPO; JPO;	
			DERWENT;	
			IBM TDB	
8	29	(((Chemical adj mechanical adj polish\$3)	USPAT;	2002/02/08
		or CMP or planariz\$5) and (slurry or	US-PGPUB;	14:57
		composition)) and (periodic adj acid)	EPO; JPO;	i
			DERWENT;	
15	1	((((Chemical adj mechanical adj polish\$3	IBM TDB	2002/02/02
	•) or CMP or planariz\$5) and (slurry or	USPAT; US-PGPUB;	2002/02/08
		composition)) and (periodic adj acid))	EPO; JPO;	15:10
		and (ammonium adj nitrate\$1)	DERWENT;	
		and (animonical day intolucevily	IBM TDB	
22	18	((((Chemical adj mechanical adj polish\$3	USPAT;	2002/02/08
) or CMP or planariz\$5) and (slurry or	US-PGPUB;	15:12
		composition)) and (periodic adj acid))	EPO; JPO;	
		and ((ammonium adj nitrate\$1)or (ammonium	DERWENT;	
		near3 salt\$1))	IBM TDB	